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附錄

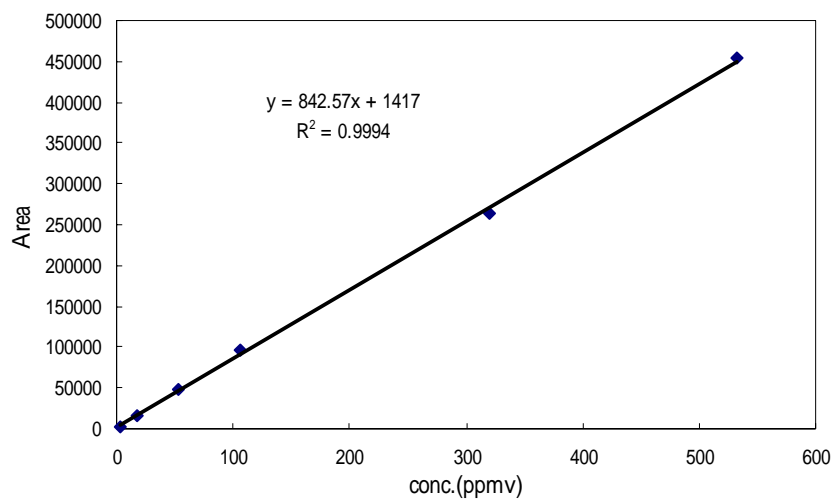


圖 2. 異丙醇標準氣體之檢量線

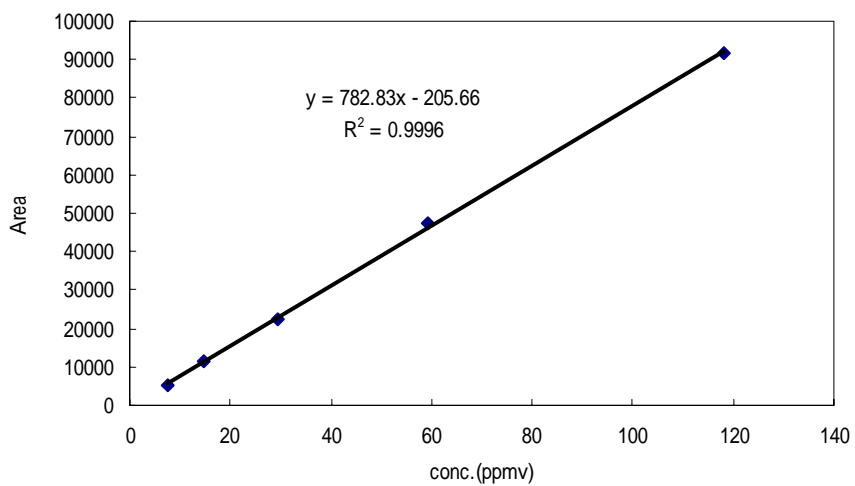


圖 2. 丙酮標準氣體之檢量線